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# Direct electrochemical formation of nanostructured amorphous $\text{Co}(\text{OH})_2$ on gold electrodes with enhanced activity for the oxygen evolution reaction†

Md Abu Sayeed, Tenille Herd and Anthony P. O'Mullane\*

The oxides of cobalt have recently been shown to be highly effective electrocatalysts for the oxygen evolution reaction (OER) under alkaline conditions. In general species such as  $\text{Co}_3\text{O}_4$  and  $\text{CoOOH}$  have been investigated that often require an elevated temperature step during their synthesis to create crystalline materials. In this work we investigate the rapid and direct electrochemical formation of amorphous nanostructured  $\text{Co}(\text{OH})_2$  on gold electrodes under room temperature conditions which is a highly active precursor for the OER. During the OER some conversion to crystalline  $\text{Co}_3\text{O}_4$  occurs at the surface, but the bulk of the material remains amorphous. It is found that the underlying gold electrode is crucial to the materials enhanced performance and provides higher current density than can be achieved using carbon, palladium or copper support electrodes. This catalyst exhibits excellent activity with a current density of  $10 \text{ mA cm}^{-2}$  at an overpotential of 360 mV with a high turnover frequency of  $2.1 \text{ s}^{-1}$  in 1 M NaOH. A Tafel slope of  $56 \text{ mV dec}^{-1}$  at low overpotentials and a slope of  $122 \text{ mV dec}^{-1}$  at high overpotentials is consistent with the dual barrier model for the electrocatalytic evolution of oxygen. Significantly, the catalyst maintains excellent activity for up to 24 h of continuous operation and this approach offers a facile way to create a highly effective and stable material.

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## Introduction

The development of electrocatalytically active nanomaterials is a crucial research endeavour given the ever increasing energy demands of our society. This is because electrocatalysis is at the core of many technologies related to the generation, conversion and potential storage of energy in a sustainable and clean manner.<sup>1–6</sup> Indeed the most significant hurdle preventing the uptake of renewable energy technology is storage.<sup>7</sup> Although there have been many significant developments in the battery space there is still an urgent need to implement large scale storage technologies. The electrochemical splitting of water into oxygen and hydrogen is one such method as it is a very attractive way to store the electricity generated from intermittent renewable energy sources such as wind and solar as a fuel.<sup>8,9</sup> However, the generation of hydrogen from water *via* photochemical, photoelectrochemical or electrochemical methods is still an ongoing challenge due to the inherent chemical stability of

water. At the heart of the electrolysis of water are electrocatalytic reactions that generate hydrogen and oxygen where production of the latter is particularly more problematic than the former. There is a large overpotential associated with the evolution of oxygen from water (greater than the theoretical value of 1.23 V) and generally the kinetics of this reaction is sluggish at many materials. There can also be issues associated with deactivation of the catalyst *via* electrodisolution, in particular at the most active  $\text{IrO}_2$  and  $\text{RuO}_2$  which are not stable over prolonged periods in alkaline conditions<sup>10–12</sup> due to the potential required to maintain the reaction at a reasonable rate.

A particularly interesting material that has shown significant activity for the oxygen evolution reaction (OER) is cobalt oxide, generally with the composition  $\text{Co}_3\text{O}_4$ .<sup>13–24</sup> Among the many alternative metal oxides to iridium and ruthenium, those of iron, nickel and cobalt have gained significant attention due to the balance between cost and activity as well as their tolerance to conditions of high pH. Lyons *et al.*<sup>11</sup> have performed an extensive study on the applicability of oxides of these metals to the OER where they considered dimensionally stable anode type electrodes, hydrous oxide electrodes and bulk oxide/hydroxide electrodes. In that study it was concluded that there is emerging evidence that the acid/base behaviour of the transition metal oxides can be ascribed to the presence of active octahedrally co-ordinated surface groups or

School of Chemistry, Physics and Mechanical Engineering, Queensland University of Technology (QUT), GPO Box 2434, Brisbane, QLD 4001, Australia. E-mail: anthony.omullane@qut.edu.au

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oxidation of a cobalt metal electrode at 100 V for 1.5 h in deionised water.<sup>44</sup> However to date  $\text{Co(OH)}_2$  has been investigated mainly for its applicability in supercapacitor applications<sup>43,44</sup> or as a precursor to the formation of  $\text{CoOOH}$  and  $\text{Co}_3\text{O}_4$  materials for the OER.<sup>17</sup>

Given the current cross-over effect that was observed in Fig. 1 the nucleation-growth mechanism was analysed by performing current-time transients (Fig. 1b) and treating the data by the Hills-Scharifker method.<sup>45</sup> This theory describes two limiting cases, *i.e.* progressive and instantaneous growth mechanisms, for the initial stages of 3D nucleation and 2D growth of deposited nuclei. These processes can be described by the following

$$\left(\frac{I}{I_m}\right)^2 = \frac{1.2254}{t/t_m} \left\{ 1 - \exp \left[ -2.3367 \left(\frac{t}{t_m}\right)^2 \right] \right\}^2 \quad (3)$$

which represents 3D progressive nucleation and 2D growth and

$$\left(\frac{I}{I_m}\right)^2 = \frac{1.9542}{t/t_m} \left\{ 1 - \exp \left[ -1.2564 \left(\frac{t}{t_m}\right) \right] \right\}^2 \quad (4)$$

which represents 3D instantaneous and 2D growth. Upon plotting the experimental data in the dimensionless form *via* a plot of  $(I/I_m)^2$  versus  $(t/t_m)$  it can be seen that the best fit is achieved at early times ( $< 2$  s) for the instantaneous nucleation of  $\text{Co(OH)}_{2(s)}$  on the electrode surface. After 2 s the data deviates from the theoretical curve.

The reason for this becomes evident when the SEM images of the deposit are examined which indicate the formation of a layered sheet like morphology (Fig. 2) where there is some evidence of cracks within a top layer that is covering the underlying lamellar structures. The Hills-Scharifker model assumes the deposition of hemispherical nuclei which grow in a uniform manner which is clearly not the case here and is significantly different to the deposition of metals such as Cu, Au and Pt for instance. The formation of lamellar type structures *via* electrodeposition at  $-0.95$  V for 60 s, as seen more evidently in Fig. 2b, is highly indicative of the formation of  $\text{Co(OH)}_2$ .<sup>43,44</sup>

This is verified by XPS data in Fig. 3a which shows the deconvoluted Co 2p<sub>3/2</sub> spectrum which is consistent with previously reported spectra for  $\text{Co(OH)}_2$ .<sup>44,46</sup> The O 1s spectrum shows a single component at 531.5 eV which is indicative of bound hydroxide groups.<sup>44</sup> Further evidence for the presence of



Fig. 3 XPS spectra of Co 2p (left panel) and O 1s (right panel) of (a) as deposited  $\text{Co(OH)}_2$  on Au and (b) after 5 cycles into the OER region.

the  $\text{Co}^{2+}$  oxidation state is seen in the expanded Co 2p spectrum (Fig. S1†) which clearly shows the presence of characteristic satellite peaks at 784.4 and 802.9 eV. The Raman data shown in Fig. 4 is indicative of  $\text{Co(OH)}_2$  (ref. 46) however there is a distinct peak at  $194 \text{ cm}^{-1}$  which could indicate some  $\text{Co}_3\text{O}_4$  may have also formed.<sup>46</sup> Taking the XPS data into consideration and its low penetration depth suggests that the top layer is  $\text{Co(OH)}_2$  with the possibility of some  $\text{Co}_3\text{O}_4$  beneath this layer. The electrodeposited material is also amorphous as evidenced by the lack of any features in the XRD pattern (Fig. S2†). The preparation of an amorphous material may in fact be quite beneficial as amorphous  $\text{Co(OH)}_2$  has been reported to have superior properties over the crystalline form for capacitor applications due to an increased number of transportation channels through the material,<sup>44</sup> which in principle would also be advantageous for electrocatalytic applications. This material is significantly different to  $\text{Co(OH)}_2$  generated electrochemically from an alkaline solution of tris(ethylenediamine)cobalt(III) where crystalline  $\beta\text{-Co(OH)}_2$  with a distinct disk-like morphology was formed. This material was found to be active



Fig. 2 (a and b) SEM images of  $\text{Co(OH)}_2$  electrodeposited on to a Au electrode at a potential of  $-0.95$  V for 60 s in a solution of 10 mM  $\text{Co(NO}_3)_2 \cdot 6\text{H}_2\text{O}$ .



Fig. 4 Raman spectra of (a) as deposited  $\text{Co(OH)}_2$  on Au and (b) after 5 cycles into the OER region.

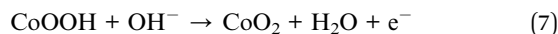


for the OER, but no quantitative information with regards to overpotential or Tafel slope was provided.<sup>47</sup> In a later publication  $\beta$ -Co(OH)<sub>2</sub> was electrochemically converted to CoOOH at elevated temperatures and also to Co<sub>3</sub>O<sub>4</sub> *via* thermal annealing at 300 °C in air and studied for the OER but no direct comparison to the catalytic performance of  $\beta$ -Co(OH)<sub>2</sub> was made.<sup>17</sup>

In this work, the OER was studied in 1 M NaOH to see if the electrodeposited amorphous Co(OH)<sub>2</sub> was active. In comparison to Co(OH)<sub>2</sub> electrodeposited on GC, Pd and Cu under identical conditions, the current associated with the OER from *ca.* 0.45 V until the end of the sweep is significantly higher at the Co(OH)<sub>2</sub>/Au electrode (Fig. 5a). It should be noted that the current has been normalised to the geometric area of the electrodes. On the first cycle it can be seen that there are two peaks at 0.97 and 1.06 V, which are attributed to oxidation of Co(OH)<sub>2</sub> *via* the following:



followed by a second broader and significantly smaller oxidation process at *ca.* 1.37 V attributed to



However in reality the process is far more complicated and as discussed by Burke likely to involve the formation of hydrous oxides<sup>48</sup> as well as species such as [Co(CoO)(CoOOH)·xH<sub>2</sub>O] as proposed by Gomez Meier.<sup>49</sup> It is clear that there is only a minor reduction process on the reverse sweep indicating that irreversible oxidation of Co(OH)<sub>2</sub> occurs. This is even more apparent on the 5th cycle (Fig. 5b) where the oxidation of Co(OH)<sub>2</sub> is significantly reduced. For the Cu electrode there are additional processes in the anodic sweep from 0.70 to 1.00 V

which are attributed to the oxidation of Cu to Cu<sub>2</sub>O and the oxidation of both Cu and Cu<sub>2</sub>O to a mixture of Cu(OH)<sub>2</sub> and CuO.<sup>50</sup> It is likely that such extensive oxidation of the surface with oxides of Cu inhibit the activity of the surface for the OER as it is known that only appreciable current densities can be achieved at copper oxides at overpotentials of *ca.* 0.60 V or greater.<sup>51</sup> It should be pointed out that the charge associated with Co(OH)<sub>2</sub> oxidation on Au is slightly greater than that observed on GC, Pd and Cu (Fig. 5a). This is quite surprising given that the charge passed during the electrodeposition process was 2.4, 4.2, 5.2 and 7.6 mC for Au, GC, Pd and Cu electrodes respectively (Fig. S3†). However the charge passed for the oxidation of Co(OH)<sub>2</sub> on the 5th cycle is comparable (Fig. 5b), yet the OER current is significantly higher when deposited on Au compared to all other electrodes. This clearly demonstrates the benefit of electrodepositing this material on the surface of Au rather than carbon, Pd or Cu. The influence of morphology can be ruled out as Co(OH)<sub>2</sub> electrodeposited on GC (Fig. S4†) under the same conditions has the same lamellar type structure as shown in Fig. 2 on Au. Therefore this is further evidence that there is a strong synergism between Co(OH)<sub>2</sub> and Au that is facilitating the OER.

There is still much speculation on the active site involved in the OER but there is significant evidence for the participation of Co<sup>IV</sup> cations during the reaction which can be enhanced by the presence of Au (ref. 18) and is consistent with the data presented here in that the activity at the carbon, palladium and copper electrodes are lower in terms of current density. After 5 cycles of the potential the Au/Co(OH)<sub>2</sub> electrode, as well as the other systems, maintains activity for the OER while there is a significant decrease in the processes associated with the oxidation of Co(OH)<sub>2</sub> which is expected given the irreversible nature of this process as discussed above. The Au/Co(OH)<sub>2</sub> electrode was then investigated *via* XPS (Fig. 3b) and Raman spectroscopy (Fig. 4) after 5 cycles of the potential into the OER region, where it was found that the composition had changed slightly. The XPS data indicated the likely formation of Co<sub>3</sub>O<sub>4</sub> (Fig. 3b)<sup>46</sup> where it can also be seen in Fig. S1† that the satellite peaks are more suppressed compared to the as-deposited material. The O 1S spectrum is also split into two components which is consistent with some Co<sub>3</sub>O<sub>4</sub> formation. This would be expected under the conditions employed of cycling the electrode 5 times to an upper limit of 0.70 V.<sup>17</sup> The Raman data is less convincing as there are only minor shifts in the peak positions which could indicate the presence of both Co(OH)<sub>2</sub> and Co<sub>3</sub>O<sub>4</sub> materials. Given that the penetration depth of XPS is *ca.* 10 nm indicates that the Co<sub>3</sub>O<sub>4</sub> material that is formed is confined largely to the surface. SEM images of the surface after the OER (Fig. 6) showed that the surface morphology doesn't change significantly compared to the as-deposited material (Fig. 2). The bulk of the material also remains amorphous when the XRD data is considered as no distinct peaks were observed (Fig. S2b†). These data suggests therefore that there is not a large scale conversion of the as-deposited Co(OH)<sub>2</sub> material into Co<sub>3</sub>O<sub>4</sub>, and that it is essentially limited to the surface. This is consistent with previous reports where it was found that for full conversion of Co(OH)<sub>2</sub> into higher oxidation states required

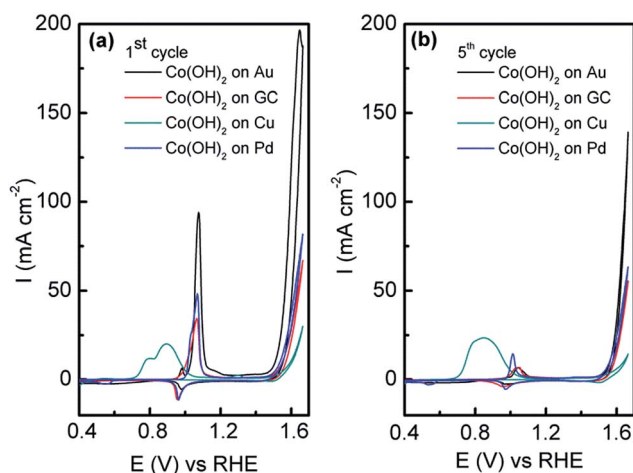


Fig. 5 Cyclic voltammograms recorded at Co(OH)<sub>2</sub> electrodeposited on Au and GC electrodes and an unmodified Au electrode in 1 M NaOH recorded at 50 mV s<sup>-1</sup> showing (a) the first cycle and (b) the fifth cycle.





Fig. 6 SEM images of electrodeposited  $\text{Co(OH)}_2$  on the Au electrode after the OER performed for 5 cycles under the conditions of Fig. 5.

electrochemical oxidation at  $95^\circ\text{C}$  *via* slow potential cycling at  $1\text{ mV s}^{-1}$  over the region encompassing  $\text{Co(OH)}_2$  oxidation.<sup>17</sup> However, a consequence of the OER performed here is that the lamellar structure becomes more defined and the overall structure is significantly more open and porous which can be attributed to the vigorous evolution of oxygen from the surface which is very visible by eye at a potential of 1.67 V.

The Au/ $\text{Co(OH)}_2$  system was then optimised to attain the best possible OER performance and therefore the effect of deposition potential (Fig. S5†) was carried out where it was found that a potential of  $-0.95\text{ V}$  was the optimum value. When the SEM images are considered (Fig. S6†); films that are deposited at a less negative potential of  $-0.75\text{ V}$  show the distinctive lamellar type structures, however they are slightly patchy and the outer continuous type layer is absent as seen in Fig. 2. However after potential cycling experiments like those in Fig. 5, there is clear degradation of the film which explains the reduced activity. At more negative deposition potentials of  $-1.40\text{ V}$ , there is more extensive coverage on the electrode surface but the morphology is much less uniform than seen for the case at  $-0.95\text{ V}$ . This is also reflected in data obtained *via* linear sweep voltammetry for  $\text{Co(OH)}_2$  electrodeposited at various times which covers the potential range for  $\text{Co(OH)}_2$  oxidation only (Fig. S7†). There is an increase in the magnitude of the oxidation process when  $\text{Co(OH)}_2$  was electrodeposited at  $-0.75$  to  $-0.95\text{ V}$  but this dramatically decreases at more negative potentials. This indicates that the amount of electrochemically active material is greatest when an applied electrodeposition potential of  $-0.95\text{ V}$  is used and hence gives the highest OER response. When a constant deposition potential of  $-0.95\text{ V}$  was used and the time was varied it was found that 60 s was the optimum time for OER activity (Fig. 7). The SEM images (Fig. S8†) show that at a lower time of 10 s that an open porous lamellar structured film is obtained that maintains its morphology after the OER. For 90 s deposition there is clear evidence of a continuous film covering the lamellar structures which is also cracked. After OER experiments the film is quite dense with less evidence of a porous morphology or lamellar structures seen for the optimum case of 60 s deposition. Therefore it appears that an open porous structure consisting of lamellar  $\text{Co(OH)}_2$  where the underlying Au electrode is accessible to a certain extent is the optimum condition for this electrode system. There is clearly a minimum coverage of  $\text{Co(OH)}_2$  however that is required as the much lower deposition times from 1–10 s were not as active.



Fig. 7 (a) Tafel plots showing OER performance for Au/ $\text{Co(OH)}_2$  electrodeposited from  $10\text{ mM Co(NO}_3)_2 \cdot 6\text{H}_2\text{O}$  at different deposition time, (b) effect of hydroxide ion activity on OER. The cyclic voltammetric experiments used to obtain the data was recorded at a sweep rate of  $1\text{ mV s}^{-1}$  in  $1\text{ M NaOH}$ .

However it is quite significant that  $\text{Co(OH)}_2$  deposited for only 1 s shows quite good activity for the OER. This is consistent with previous work where multilayers of  $\text{Co}_3\text{O}_4$  deposited on gold were less effective for the OER,<sup>18</sup> *i.e.* for gold to promote  $\text{Co}^{\text{IV}}$  formation, the overlying active material should not be too thick to allow for effective electron transfer. Therefore maximising the active material/Au contact interface should be beneficial for the greatest activity. It should be noted that the Au electrode is not active for OER over the potential range of interest (Fig. S9†).

This result is also consistent with the trend in OER activity for  $\text{Co}_3\text{O}_4$  deposited on other electrodes such as Cu, Pt and Pd.<sup>18</sup> The same trend is observed here in that the activity of  $\text{Co(OH)}_2$  follows the order of  $\text{Au} > \text{Pd} > \text{Cu}$ . This was explained in terms of the electronegativity of the underlying electrode in that Au being the most electronegative would facilitate the oxidation of  $\text{Co}^{\text{II}}$  and  $\text{Co}^{\text{III}}$  into the  $\text{Co}^{\text{IV}}$  active species to a greater extent than the less electronegative metals such as Pd and Cu. Previous density functional theory calculations have showed that the d-band centre of Co on Au shifts positively by 0.74 eV relative to pure Co. This higher d-band centre results in a stronger Co–O bond thereby making Co easier to oxidise.<sup>13</sup> Evidence for this is shown in Fig. S10† where the oxidation of  $\text{Co}^{\text{II}}$  to  $\text{Co}^{\text{III}}$  occurs as a distinct peak at the Au electrode at a lower potential compared to the other electrodes where broad shoulders are seen for this process prior to the main peak at *ca.* 1.06 V. Also the broad peak for oxidation into  $\text{Co}^{\text{IV}}$  at *ca.* 1.37 V is more readily observable at Au compared to the other electrodes. The latter observation has also been reported by Zhao *et al.* for gold nanoparticles incorporated into mesoporous  $\text{Co}_3\text{O}_4$  compared to mesoporous  $\text{Co}_3\text{O}_4$  only.<sup>21</sup> The rate limiting step for the OER has been postulated to be the reaction of  $\text{OH}^-$  with adsorbed O atoms on the surface to form adsorbed OOH species. Once this species is formed it reacts with more  $\text{OH}^-$  ions to give adsorbed  $\text{O}_2$  and  $\text{H}_2\text{O}$  where finally  $\text{O}_2$  desorbs from the surface. The  $\text{Co}^{\text{IV}}$  species enhances the electrophilicity of the adsorbed O atoms which *via* nucleophilic attack with  $\text{OH}^-$  ions forms O–OH species. In addition  $\text{Co}^{\text{IV}}$  has been postulated to aid in the deprotonation of these OOH species to form  $\text{O}_2$ .<sup>18</sup>



Recently a significant insight into the OER on cobalt based materials has been reported by Strasser.<sup>32</sup> In that study they found that crystalline  $\text{Co}_3\text{O}_4$  is converted into X-ray amorphous  $\text{CoO}_x(\text{OH})_y$  containing di- $\mu$ -oxo bridged  $\text{Co}^{3+/4+}$  ions during high rates of oxygen evolution. Once the material returns to non-catalytic conditions it recrystallizes to  $\text{Co}_3\text{O}_4$  and this process was found to be reversible. Therefore we electrodeposited  $\text{Co}(\text{OH})_2$  onto a gold coated TEM grid (2–3 nm thick) and investigated it for the OER. The TEM grid consists of gold islands dispersed over the carbon coated grid (Fig. 8a). Comparable OER activity to that of the Au electrode was found for  $\text{Co}(\text{OH})_2$  electrodeposited on the Au TEM grid (Fig. 8b). When the surface was analysed it was found that  $\text{Co}(\text{OH})_2$  was deposited to an equal extent over all areas of the grid and not exclusively to the areas with a high coverage of gold (Fig. S11†). Significantly it was found after the OER that some of the cobalt species was in fact crystalline in nature as shown in Fig. 8c and d. This crystalline material was found on both the gold and carbon rich areas of the grid. The lattice fringe with an interplanar spacing of 0.23 nm (Fig. 8d) is ascribed to the (111) plane of Au (ref. 52) but there are also lattice fringes with an interplanar spacing of 0.275 nm evident which can be indexed to  $\text{Co}_3\text{O}_4$  species.<sup>24</sup> This is in agreement with the XPS data recorded after the OER on the Au electrode (Fig. 3b) which showed the formation of  $\text{Co}_3\text{O}_4$ . Therefore in this case it appears that once  $\text{Co}(\text{OH})_2$  partakes in the OER and  $\text{Co}^{\text{IV}}$  species are created as the active material, they are subsequently converted to the more stable crystalline form upon return to non-catalytic conditions. As indicated by the GIXRD data (Fig. S2b†) this conversion is limited to the surface of the material which is in agreement with Strasser's observations.

For the optimised Au/ $\text{Co}(\text{OH})_2$  system, the onset potential for the OER is 1.48 V. Significantly a current density of  $10 \text{ mA cm}^{-2}$  can be achieved at an overpotential ( $\eta$ ) of 360 mV greater than the theoretical value of 1.23 V. From a Tafel plot analysis (Fig. 7a) the Tafel slope was found to be  $56 \text{ mV dec}^{-1}$  with an

exchange current density ( $j_0$ ) of  $1.8 \times 10^{-10} \text{ A cm}^{-2}$ . It was also found that the Tafel slope ( $56 \text{ mV} \pm 4 \text{ mV}$ ) is independent of the electrodeposition time (calculated from Fig. 7a). The lower activity achieved for  $\text{Co}(\text{OH})_2$  on the different electrodes is also reflected in the Tafel slopes of 59, 61 and  $74 \text{ mV dec}^{-1}$  recorded for C, Pd and Cu respectively. The Tafel slope value for the gold supported material is lower than that reported recently for  $\text{Co}_3\text{O}_4$  supported on reduced graphene oxide ( $68 \text{ mV dec}^{-1}$ ),<sup>14</sup> where a lower Tafel slope is indicative of a more active electrocatalyst. The performance of this material is also comparable to a graphene- $\text{Co}_3\text{O}_4$  sandwich structure ( $10 \text{ mA cm}^{-2}$  at  $\eta = 313 \text{ mV}$  in 1 M NaOH with a Tafel slope of  $56 \text{ mV dec}^{-1}$ ),<sup>24</sup> however the method of synthesis here is more facile compared to a multistep chemical synthesis including a calcination step followed by immobilisation onto an electrode surface secured *via* a Nafion coating. It is also comparable to the OER activity in 1 M NaOH for  $\text{Co}_3\text{O}_4$  (Tafel slope of  $61 \text{ mV dec}^{-1}$ ,  $j_0 = 6.0 \times 10^{-9} \text{ A cm}^{-2}$ ) and  $\text{CoOOH}$  (Tafel slope of  $54 \text{ mV dec}^{-1}$  and  $j_0 = 1.2 \times 10^{-10} \text{ A cm}^{-2}$ ) formed *via* conversion of electrodeposited  $\beta\text{-Co}(\text{OH})_2$ ,<sup>17</sup> but again the approach taken in this study is advantageous in that only a simple one step room temperature deposition process is required. In comparison to a commercial catalyst such as  $\text{IrO}_x$ , a current density of  $10 \text{ mA cm}^{-2}$  in 1 M NaOH can be achieved at an overpotential of 0.32 V (ref. 53) which shows the applicability of the Au/ $\text{Co}(\text{OH})_2$  material. As discussed above, the Tafel slope at low overpotentials is  $56 \text{ mV dec}^{-1}$  and in this region a reaction order  $m\text{OH}^- = 1.2$  was determined (Fig. 7b). The Tafel slope changes to  $122 \text{ mV dec}^{-1}$  at higher overpotentials and taking the pH dependence into account is consistent with the analysis undertaken by Lyons *et al.* for an aged Co substrate that had been subjected to extensive potential cycling where an oxide layer had built up on the electrode surface.<sup>54</sup> They proposed a dual barrier model to explain the change in the OER kinetic data whereby an inner anhydrous oxide layer is covered by a more dispersed hydrous oxide layer. Ionic transport through the inner layer is more difficult but charge percolation through the outer hydrous oxide layer is facile. The active site for the OER was proposed to be  $[\text{Co}(\text{iv})\text{O}_m(\text{OH})_n]^{p-}$  ( $p = 2m + n - 4$ ) rather than discrete  $\text{CoO}_2$  species described in eqn (7).

The turnover frequency (TOF), which is used extensively in the molecular catalysis area, can also be utilised for electrocatalytic reactions. The TOF is defined as the number of molecules reacting for a given reaction per unit time. As outlined by Lyons *et al.* the electrochemical equivalent of the TOF can be written as:<sup>55</sup>

$$\text{TOF} = 1N_A/4FN_{\text{atoms}} = J/4Q \quad (8)$$

where  $N_A$  is Avagadro's number,  $F$  is Faraday's constant,  $N_{\text{atoms}}$  is the number of atoms or active sites,  $J$  is the current density and  $Q$  is the charge associated with the oxidation of  $\text{Co}(\text{OH})_2$  at *ca.* 1.1 V. In this case the charge associated with  $\text{Co}(\text{OH})_2$  oxidation on the first cycle (Fig. 5a) is utilised which has a value of 10 mC. When taking a current density value of  $10 \text{ mA cm}^{-2}$  at an overpotential of 360 mV gives a TOF value of  $0.25 \text{ s}^{-1}$ . If the stable voltammogram after 5 cycles is considered (Fig. 5b) the



Fig. 8 HR-TEM images of (a) pristine Au grid, (b) OER performance comparison; CV were recorded at  $50 \text{ mV s}^{-1}$  in 1 M NaOH, (c)  $\text{Co}(\text{OH})_2$  deposited on Au support, (d) magnified HR-TEM images showing lattice spacing of  $\text{Co}_3\text{O}_4$  and Au.





Fig. 9 Stability measurements of Au/Co(OH)<sub>2</sub> held at 1.67 V for 24 h in 1 M NaOH.

charge involved in the oxidation process is 1.2 mC which gives a TOF value of 2.1 s<sup>-1</sup>. These values are comparable to many previous reports on cobalt oxide materials and even nickel oxides.<sup>55</sup>

The stability of the Au/Co(OH)<sub>2</sub> material was then investigated over a period of 24 h where an overpotential of 440 mV was applied (Fig. 9). After the initial drop in the current density over the first hour, from 45 to 35 mA cm<sup>-2</sup>, there is only a gradual decrease in activity over the next 23 hours where a current density of 25 mA cm<sup>-2</sup> was maintained. The noise in the trace is due to the evolution of oxygen bubbles from the surface of the electrode. This clearly indicates that a film deposited from a relatively dilute precursor metal salt for a period of only 60 s results in a highly robust material that is tolerant to quite robust oxygen evolution conditions.

## Conclusions

The direct electrochemical formation of an active amorphous Co(OH)<sub>2</sub> material has been reported that is highly active for the OER. The presence of an underlying gold electrode is critical to the performance of the catalyst and is consistent with previous work where the formation of the Co<sup>IV</sup> active site is benefited by the underlying Au electrode when compared to other metals such as Pd or Cu and follows the trend whereby increased electronegativity of the underlying metal increases OER activity. The morphology of the material can be controlled by the applied deposition potential and time where the optimum conditions was found to produce lamellar type structures that became open and porous during the course of the OER and exposed the underlying Au electrode, thereby maximising the cobalt oxide/Au interface. In addition there was evidence that the surface of the amorphous material was converted to crystalline Co<sub>3</sub>O<sub>4</sub> once the OER was completed. The mechanism of catalysis was found to be consistent with a dual barrier model and gave excellent current densities at low overpotential with a TOF as high as 2.1 s<sup>-1</sup>. In addition this activity could be maintained for up to 24 h of continuous operation. This simple approach may be of benefit for other transition metal oxides that are also active for the OER.

## Experimental

### Materials

Cobalt(II) nitrate hexahydrate (Chem-Supply), and sodium hydroxide (98%) (Sigma-Aldrich) were used as received from the suppliers and made up with deionised water (resistivity of 18.2 MΩ cm) purified by use of a Milli-Q reagent deioniser (Millipore).

### Electrochemical measurements

Electrochemical measurements were undertaken at (20 ± 2) °C with a BioLogic VSP workstation and a standard three-electrode cell configuration, consisting of a working electrode, a reference electrode and a counter electrode. The reference electrode was Ag/AgCl (3 M KCl) in all experiments. For voltammetric experiments, gold (1.6 mm diameter), glassy carbon (3 mm diameter), Pd (3 mm diameter) or copper (1.6 mm diameter) from Bio-analytical Systems were used as the working electrode, and a platinum wire as an auxiliary electrode. Prior to each deposition, the surface of each electrode was mechanically polished with 0.3 μm-sized alumina powder on a Microcloth pad and rinsed in Milli-Q water. These procedures were repeated several times. For all electrochemical experiments the electrolyte solution was purged for 10 min with nitrogen prior to performing any experiments to remove dissolved oxygen from the solution. The plating solution for the electrodeposition of Co oxide nanostructures consisted of 10 mM Co(NO<sub>3</sub>)<sub>2</sub>·6H<sub>2</sub>O. The electrodeposition of Co hydroxide nanostructures onto the electrodes was optimized by varying the potential and deposition time using the chronoamperometric technique. The electrodeposited films were washed with Milli-Q water several times ensuring no residual cobalt nitrate salt remained on the surface. The deposited film was then dried under a stream of nitrogen gas.

For the OER the reproducibility of the measurements was achieved by carrying out five replicates for each experiment. In all cases *iR* correction was applied to all cyclic voltammograms and the solution was stirred at *ca.* 300 rpm using a magnetic stirrer at the bottom of the electrochemical cell. For the OER data the potential has been converted to the RHE scale *via*  $E_{\text{RHE}} = E_{\text{Ag/AgCl}} + 0.059 \times \text{pH} + 0.197 \text{ V}$ . The current density reported in this work was normalized to the geometric surface area of the electrodes.

### Physical measurements

Raman spectra were collected using an Olympus BHSM microscope, equipped with 10 and 50× objectives and part of a Renishaw 1000 Raman microscope system that is also equipped with a monochromator, a filter system, and a charge coupled device (CCD). Raman spectra were excited by a HeNe laser (633 nm) in the range between 100 and 1000 cm<sup>-1</sup>. Several acquisitions were used to improve the signal-to-noise ratio. X-ray photoelectron spectroscopy data were collected using an Omicron Multiscan Lab Ultra-high Vacuum Scanning Tunneling Microscope (UHV-STM) incorporating a 125 mm hemispherical electron energy analyser. XPS measurements were



performed using non-monochromatic Mg K $\alpha$  (1253.6 eV) X-ray source (DAR 400, Omicron Nanotechnology), 300 W incident angle at 65° to the sample surface. Wide scans were observed at an analyser pass energy of 50 eV with 0.5 eV steps and 200 ms dwell time. Narrow high-resolution scans for Co 2p, O 1s, Au 4f, and C 1s were taken at 20 eV pass energy, 0.2 eV steps, 200 ms dwell time. The base pressure in the analysis chamber was  $1.0 \times 10^{-9}$  torr and  $1.0 \times 10^{-8}$  torr when the sample was analysed. Atomic compositions of cobalt oxide surface were calculated using the CasaXPS version 2.3.15 software and a linear baseline with Kratos library Relative Sensitivity Factors (RSFs). Sample preparations for XPS measurements were same with SEM sample preparations.

SEM and EDX were performed on JEOL 7001F at an operating voltage of 5 KV and 15 KV, respectively. Samples were prepared by electrodeposition onto 100 nm thick Au coated silicon substrates following the same parameters used for the Au electrode (BAS). The surface area of the electrodeposited cobalt hydroxide film on the Au coated silicon substrates was carefully controlled using a mask (~17 mm diameter). HRTEM images were taken using a JEOL 2100 instrument at 200 KV. A high-sensitivity silicon drift X-ray detector for more accurate compositional analysis and a Gatan Orius SC1000 CCD camera is equipped for better image acquisition. Ultrathin gold supported films on 3 mm standard TEM grids (Substratek™, TED PELLA) were used as the working electrode for the electrodeposition of Co(OH)<sub>2</sub>.

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